

Power switch implementation for low voltage digital circuits

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Abstract: This letter presents a novel power switch structure using only low threshold voltage MOSFETs to extend the power switch to ultra-low voltage region. The proposed structure deploys series-connected low- V_{th} footers with two virtual ground ports and selectively chooses the logic cells for connecting to each virtual ground port according to the delay criticality. Moreover, additional circuitries are designed to reduce not only sub-threshold leakage current, but also gate-tunneling leakage and to reduce wake-up time and wake-up fluctuation compared to the conventional power switch. The total power switch size of the proposed power switch structure including the additional circuits is less than the conventional one. The simulation results show that the proposed power gating structure has advantage of low leakage power, small footer size, and low wake-up time, but high-performance, low wake-up fluctuation, wake-up power for inverter chains and ISCAS85 benchmark circuits at 1.1 V and 0.6 V V_{DD} which are designed using 45 nm CMOS technology.

Keywords: power switch, power gating, leakage power

Classification: Integrated circuits

References

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1 Introduction

The sub-threshold leakage power is significantly reduced by power switch structure (hereafter called PSS) in the standby mode [1]. However, the power switch is no longer effective in sub-1V region because the high threshold voltage (V_{th}) of the power switch degrades the operation frequency rapidly at the low voltage [2]. In this letter, in order to extend the power switch to sub-1V supply-voltage region and to reduce leakage during the sleep mode, low- V_{th} footers connected in series are deployed. For the speed improvement of the series-connected footer structure, the drain node of each footer is used as virtual ground pin, where the upper virtual ground pin is connected to the logic circuits on the non-critical paths, and the lower virtual ground pin is connected to the logic circuits on the critical paths.

2 Power switch implementation

Figure 1 (a) shows our new PSS consisting of nine low- V_{th} NMOS devices. In spite of using low- V_{th} footers, the series-connected low- V_{th} footer scheme can reduce leakage power by the stack effect and smaller footer size. However, it suffers from the reduced performance, increased ground bound, increased wake-up time, and increased wake fluctuation due to increased resistance. In order to compensate for the reduced performance, the proposed scheme uses two virtual lines as shown in Fig. 1 (a) in which M1 and M2 are strong devices (main footers), and the other weak devices are deployed for gate-tunneling leakage (hereafter called gate leakage) reduction, wake-up time, and wake-up fluctuation reduction. The first virtual ground V_{vss1} is connected to the gates on the non-critical paths because two serial footers (M1 and M2) reduce leakage current during sleep mode but increase gate delay during active mode. On the other hand, the second virtual ground V_{vss2} is connected to the gates on the critical paths because one footer (M1) reduces gate delay during active mode and still can reduce certain amount of leakage current during sleep mode.

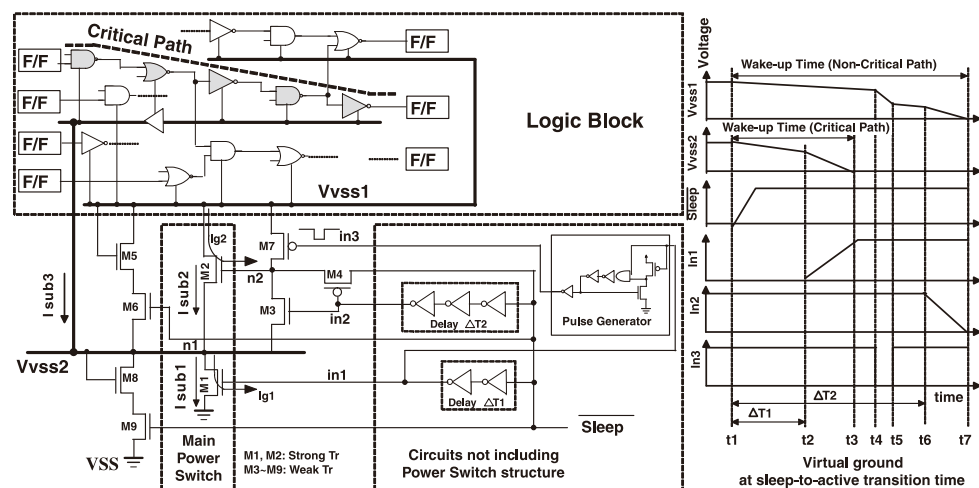
In order to further reduce the delay and ground bounce for the critical paths, M2 size should be greater than M1; the total size of the proposed power switch consisting of NMOS is smaller than one footer size of the conventional power switch because the reduced width of the footer can be compensated with the low- V_{th} and thin oxide thickness. The reason is that in active mode the footer operates in the linear region and the footer current is given by:

$$I_{footer} \approx \mu \left(\frac{\epsilon_{ox}}{t_{ox}} \right) \left(\frac{W}{L} \right) (V_{GS} - V_{th}) V_{VSS} \quad (1)$$

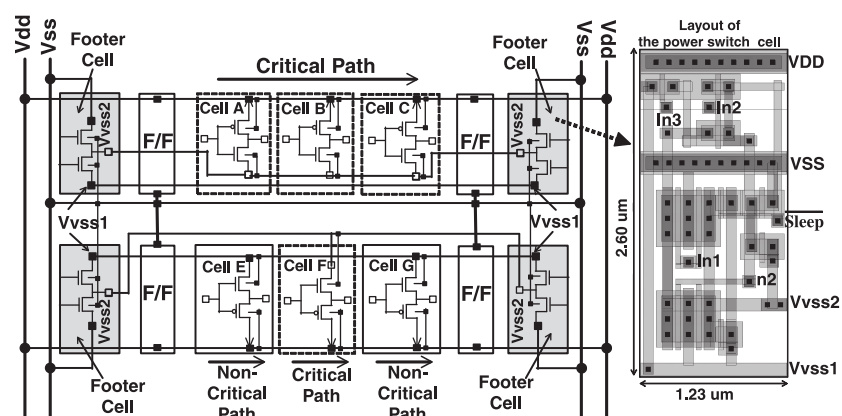
where ε_{ox} is the permittivity for SiO₂, t_{ox} is the oxide thickness, μ is the mobility, and V_{VSS} is the virtual ground voltage.

For the simple physical design of the new power switch, the new power switch cell can be placed in the same placement strategy as that of the conventional power switch except V_{vss2} : V_{vss1} is connected to the local ground rail the same as the virtual ground of the conventional power switch, whereas V_{vss2} is used as a pin to connect the ground pins of the modified logic cells on the critical paths. The lines between V_{vss2} and logic cells on the critical paths are routed as inter-cell wires. Figure 1 (b) shows the conceptual power network for the new PSS.

The leakage current during sleep mode and the wake-up time depend on the potential of each virtual ground. Under the assumption that the logic circuit is a simple inverter and the footers are biased in the weak inversion region, the steady state of each virtual VSS can be obtained by matching the



(a)



(b)

Fig. 1. (a) Block diagram of the proposed PSS, (b) Conceptual power network for the new PSS

leakage current the logic circuit with the leakage for the footers as follows:

$$V_{vss1} = \frac{-V_{th} + 4\eta V_{dd} - S \log_{10} \left(\frac{W_{Footer(M1)}^2 W_{Footer(M2)}}{W_{Circuit(Non-Critical)}^3 W_{Circuit(Critical)}} \right)}{5\eta} \quad (2)$$

$$V_{vss2} = \frac{-2V_{th} + 3\eta V_{dd} - S \log_{10} \left(\frac{W_{Footer(M2)}^2}{W_{Footer(M1)} W_{Circuit(Non-Critical)} W_{Circuit(Critical)}^2} \right)}{5\eta} \quad (3)$$

where η is the DIBL coefficient and S is the sub-threshold slope.

From Eqs. (2) and (3), V_{vss2} can be changed depending on the footer size to reduce leakage current and wake-up time of the logic circuit on the critical paths. In order to reduce the dominant gate leakage (I_{g2}), M3 is deployed where the gate-to-source voltage of M2 is almost 0 V and M2 is turned off. The voltage difference between V_{vss1} and the gate node of M2 is decreased from around V_{dd} to n_2 voltage which makes I_{g2} exponentially decrease according to gate leakage equation. During the short mode-transition time from sleep to active, the conventional power switch suffers from rush-thru current and large wake-up time [3]. In order to overcome this problem, it is suggested that the virtual ground voltage is gradually decreased using a new structure as shown in Fig. 1 (a). When M6 and M9 are turned on during short period of transition time, the two virtual grounds (V_{vss1} and V_{vss2}) start to be discharged up to a small value. After ΔT_1 induced by a delay line, M1 is turned on, and V_{vss2} is completely discharged to 0 V at t_3 (wake-up time of the circuits on the critical paths), whereas V_{vss1} is not fully discharged. From t_4 to t_5 , V_{vss1} goes down sharply through M7 where the input is a short negative pulse. After ΔT_2 induced by another delay line, M3 is turned off, and M4 is turned on. Finally, V_{vss1} is completely discharged at t_7 (wake-up time of the circuits on the non-critical paths). This gradual discharging approach considerably reduces the rush-current during mode-transition.

Figure 2 shows the delay dependence of the conventional power switch and the proposed power switch on power supply voltage for 20 inverter chains with 16 chains having 30 inverters and 4 chains having 40 inverters using 45 nm

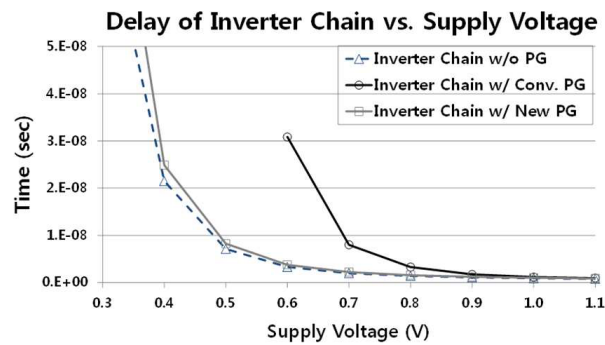


Fig. 2. Delay dependence on supply voltage of PSS

Table I. Simulation results

| (Inverter Chain) Simulation Conditions: low-V _{th} and high-v _{th} are 0.165 V and 0.524 V for NMOS, (−0.165 V and −0.524 V for PMOS), t_{ox} of low-V _{th} and high-V _{th} MOS are 1.1 nm and 1.9 nm, and temperature is 25°C for sleep mode and 125°C for active mode | | | | | | |
|---|---|--------------------|-------|-----------------------------------|-----------------|---------------------------------|
| PSS Scheme V _{dd} =1.1 V | Normalized by low-V _{th} Designed Logic Block | | | Normalized by Conventional PSS | | |
| | Avg. Leakage Power | Delay (Longest) | Area | Avg. Wake-up Power | Wake-up Time | Wake-up Noise (Peak-to-Peak) |
| Low-V _{th} Inverter Chains without PSS) | 1.000 | 1.000 | 1.000 | N/A | N/A | N/A |
| High-V _{th} Inverter Chains without PSS) | 0.002 | 6.993 | 1.000 | | | |
| Dual-V _{th} Inverter Chains without PSS) | 0.246 | 1.008 | 1.000 | | | |
| Conventional PSS | 0.024 | 1.197 | 1.100 | 1.000 | 1.000 | 1.000 |
| Multi-mode PSS | 0.015 | 1.195 | 1.103 | 1.219 | 1.083 | 1.070 |
| Two-pass PSS | 0.021 | 1.190 | 1.103 | 1.011 | 3.665 | 1.012 |
| Zigzag PSS | 0.171 | 8.342 | 1.150 | 0.577 | 0.818 | 0.919 |
| Selective PSS | 0.048 | 1.166 | 1.025 | 0.466 | 1.031 | 1.111 |
| New PSS (v _{dd} =1.1 V) | 0.025 | 1.129 | 1.064 | 1.133 | 0.454 | 0.688 |
| New PSS (v _{dd} =0.6 V) | 0.012 | 4.744 | 1.064 | 0.268 | 0.758 | 0.202 |

Note **: This simulation result shows the efficiency of the proposed power switch at 0.6 V supply voltage. For ultra-low voltage circuits such as below 0.6 V, previous high-V_{th} based PSS (Conventional PSS [1], Multi-mode PSS [4], Two-pass PSS [5], Zigzag PSS [2], and Selective PSS [6]) cannot be used due to the impractical delay increase and long wake-up time.

| (ISCAS85 Circuits) Simulation Conditions: low-V _{th} and high-v _{th} are 0.165 V and 0.524 V for NMOS, (−0.165 V and −0.524 V for PMOS), t_{ox} of low-V _{th} and high-V _{th} MOS are 1.1 nm and 1.9 nm, and temperature is 25°C for sleep mode and 125°C for active mode | | | | | | | | |
|---|---------------|--|--------------------------|-----------------------------------|-----------------------------|--------------------------|--------------------------|---------------------|
| Circuit | # of Gates | Normalized by Low-V _{th} Designed Logic Block | | Normalized by Conventional PSS | | | | |
| | | Avg. Leakage Power | Longest Path Delay | Avg. Leakage Power | Gate Leakage (Footer) | Longest Path Delay | Avg. Wake-up Power | Wake- up Time |
| C432 | 160 | 0.132 | 1.012 | 1.116 | 0.162 | 0.762 | 0.917 | 0.023 |
| C880 | 383 | 0.168 | 1.081 | 1.151 | 0.397 | 0.346 | 0.912 | 0.021 |
| C1355 | 546 | 0.127 | 1.018 | 0.884 | 0.395 | 0.627 | 1.003 | 0.025 |
| C1908 | 880 | 0.096 | 1.034 | 0.865 | 0.097 | 0.655 | 0.991 | 0.017 |
| C2670 | 1193 | 0.123 | 1.077 | 1.403 | 0.559 | 0.428 | 0.932 | 0.017 |
| C5315 | 2307 | 0.021 | 1.027 | 0.990 | 0.326 | 0.858 | 0.949 | 0.015 |
| C6288 | 2406 | 0.103 | 1.022 | 1.363 | 0.129 | 0.478 | 0.928 | 0.012 |
| C7552 | 3512 | 0.200 | 0.992 | 1.156 | 0.399 | 0.919 | 0.361 | 0.016 |
| Avg. Reduction Rate (%) | | 87.88 | -3.29 | -11.60 | 69.95 | 36.59 | 12.58 | 98.18 |

CMOS technology. The area overhead of the each power switch is 10% of the total NMOS width in the inverter chain, the 16 chains having 30 inverters are connected to V_{ss1} , and the 4 chains having 40 inverters are connected to V_{ss2} . As the supply voltage decreases below 0.8 V in active mode, the inverter chain using the proposed power switch becomes more than twice faster than the circuit using the conventional power switch, and its delay decreases by 88.24% compared to the circuit using the conventional power switch at 0.6 V. Furthermore, the conventional power switch does not work correctly below 0.6 V.

3 Simulation results and evaluation

The proposed PSS using 45 nm predictive technology model has been implemented and evaluated using inverter chains which consist of 20 inverter chains with 16 chains having 30 inverters and 4 chains having 40 inverters. In order to show the good balance of the proposed methodology among wake-up time, delay, wake-up power, wake-up fluctuation and leakage power of the PSS, the inverter chains are simulated for 11 well-known schemes and compared among them as shown in Table I. In order to show the efficiency of the new power switch at 0.6 V supply voltage, the ISCAS85 benchmark circuits are simulated for low- V_{th} logic block, conventional power switch, and the proposed power switch at the same conditions as those of the inverter chains except that the total footer size of the proposed power switch is 5% of the total NMOS width. Table I also presents the simulation results for ISCAS85 circuits: the wake-up fluctuation items for the both structures are left out because it can be ignorable (less than 0.002 V), and the total leakage is a little increased by 11.60% on average under the influence of the sub-threshold leakage; but it is expected that the total leakage is reduced much more as the technology scales down and the gate tunneling leakage current increases.

4 Conclusion

This letter proposes a novel PSS using a single low threshold voltage in ultra-low voltage nanoscale CMOS circuits. In order for the PSS to be extended to sub-1V region, two serial footers with a single low- V_{th} are used. The simulated results show that the proposed PSS is a practicable solution for high performance circuits in ultra-low voltage nanoscale CMOS in terms of leakage power, operational circuit speed, wake-up time, and ground bounce.

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